IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):

Yagihashi et al.

Filed:

Concurrently Herewith

Title:

COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND

METHOD OF FORMING THE SAME, INTERLEVEL INSULATOR FILM,

AND SEMICONDUCTOR DEVICE

Docket No.:

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Customer No.: 00826

March 26, 2004

Mail Stop Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT 37 CFR § 1.115

Sir:

Please enter this Preliminary Amendment before calculating the claim fee and amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims beginning on page 2 of this paper.

Remarks begin on page 5 of this paper.